### **Progress meeting**

Victor Calzadilla, Dominik Heiss Andrea Fiore, Meint Smit

#### 17/06/2013

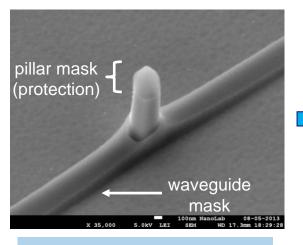




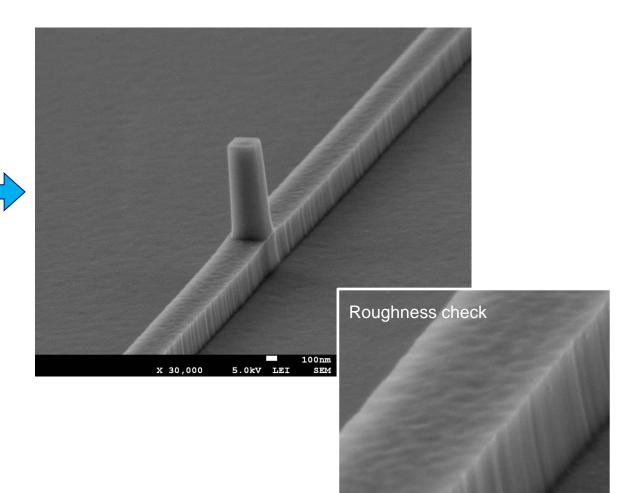
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Where innovation starts

# Nanopillar on waveguide structure was achieved



 Before etching the waveguide







5.0kV

TE

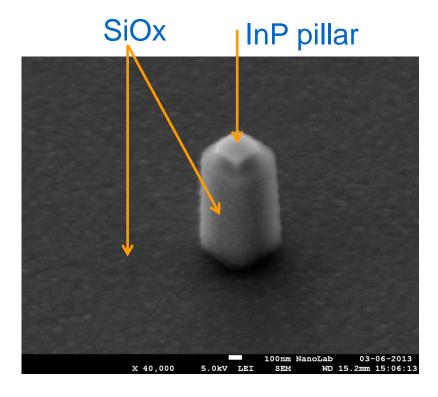
X 110,000

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100nm NanoLak

## **Planarization tests with photoresist**

 Successful planarization testes were done.
Planarization is needed to open the dielectric on top of pillar and to deposit contacts



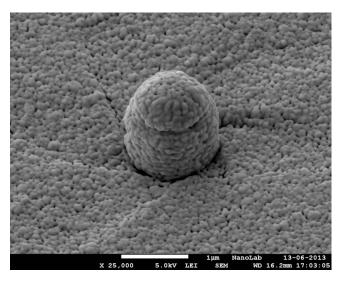
Contacts (Ti/Pt/Au)



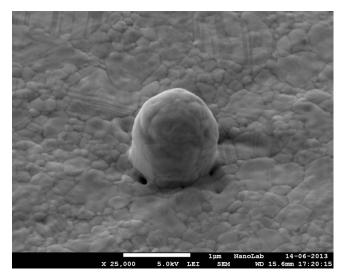
# Silver deposition and annealing

• First Ag deposition on pillars and annealing done

#### After Ag deposition



#### After annealing





- Received bonded wafer (IIIV-Si) from IMEC
- Simulations on grating couplers done
- Next fabrication activities:
  - Fabrication of undercut (dry or wet?)
  - Fabrication of gratings
- D7.3 on dissemination and promotion activities <u>"Mirror</u> deliverable of 7.1, which will be available to the public on the website" is online.

